## New operation modes and online diagnostics at FLASH.



S. Düsterer for the FLASH team

5 way meeting, 24<sup>th</sup> October 2016









- > FLASH = FLASH1 + FLASH2
- Novel options at FLASH2
- > Online photon diagnostics at FLASH
- > Future plans







### **FLASH – Running two FELs in parallel**





### FLASH @ DESY



Photon beam (SASE)	FLASH 1	FLASH 2
Wavelength	4.2-52nm	3.1-90nm
Pulse Energy	1-500µJ	1-1000µJ
Pulse Duration (FWHM)	<30-200fs	<30-200fs
Pulses per second	10-8000	10-8000



# New record in average power (FLASH1) 4000 pulses with 200µJ @ 11nm $\rightarrow$ 0.8 W



#### **FLASH2 – Fast Tunability**





## **FLASH2 - Exploring Wavelengths lower than FLASH1**

## DESY

#### Marion Kuhlmann

 $\lambda_{\text{FLASH2}} \sim \lambda_{\text{FLASH1}}$  to 3 x  $\lambda_{\text{FLASH1}}$ 



#### **FLASH2 - New Operation Modes**







#### User schedule FLASH1 (Oct / Nov 16)

#### User schedule FLASH2 (Oct / Nov 16)

Oct/Nov 2016 ELASH1 - Block3 last undate: 06 10 2016 (channes Ulinch and 14 11 -19 11 El 1+2)										Oct/Nov 2016, FLASH 2 - Block3							last update: 5.9.2016 (2x Moshammer/Schnorr scheduled, shutdown entered)									
setup time day shift (7:00-19:00)						night si	night shift (19:00 -7:00)							day shift (7:00-19:00)					night shift (19:00 -7:00)							
24.10.16 Mo	4 Schnell		30.3 nm	BL1	L	11001711	Schnell	30.	nm BL1	L	110017	/11	24.10.16	5 Mo 6	Moshammer/Schnorr	51.8 nm	FL26		11000976		Moshammer/Schnorr		51.8 nm	FL26	11000976	
25.10.16 Tu	5 Martins		14.9 nm	PG2	SD	0 11001717	Martins	14.5	)nm PG2		SD 110017	717	25.10.16	5 Tu	FL2 Operation	14.9 nm -	44.7 nm				FL2 Operation	1-	4.9 nm -	44.7 nm		
26.10.16 We	4 Schnell		30.3 nm	BL1	L	11001711	Schnell	30.	nm BL1	L	110017	711	26.10.16	5 We 5	Moshammer/Schnorr	51.8 nm	FL26		11000976		Moshammer/Schnorr		51.8 nm	FL26	11000976	
27.10.16 Th	Schnell		30.3 nm	BL1	L	11001711	Schnell	30.	nm BL1	L	110017	/11	27.10.16	5 Th	Moshammer/Schnorr	51.8 nm	FL26		11000976		Moshammer/Schnorr		51.8 nm	FL26	11000976	
28.10.16 Fr	5 Martins		14.9 nm	PG2	SE	0 11001717	Martins	14.	9 nm PG2		SD 110017	17	28.10.16	5 Fr	FL2 Operation	14.9 nm -	44.7 nm				FL2 Operation	1-	4.9 nm -	44.7 nm		
29.10.16 Sa	Martins		14.9 nm	PG2	SE	0 11001717	Martins	14.5	nm PG2		SD 110017	17	29.10.16	5 Sa	FL2 Operation	14.9 nm -	44.7 nm				FL2 Operation	1-	4.9 nm -	44.7 nm		
30.10.16 Su	4 Schnell		30.3 nm	BL1	L	11001711	Schnell	30.	8 nm BL1	L	110017	/11	30.10.16	5 Su 5	Moshammer/Schnorr	51.8 nm	FL26		11000976		Moshammer/Schnorr		51.8 nm	FL26	11000976	
31.10.16 Mo	Schnell		30.3 nm	BL1	L	11001711	Schnell	30.	3 nm BL1	L	110017	711	31.10.16	5 Mo	Moshammer/Schnorr	51.8 nm	FL26		11000976		Moshammer/Schnorr		51.8 nm	FL26	11000976	
1.11.16 Tu	Contingenc	(user @ FL2)					Contingency (us	ser @ FL2)					1.11.16	5 Tu	Moshammer/Schnorr	51.8 nm	FL26		11000976		Moshammer/Schnorr		51.8 nm	FL26	11000976	
2.11.16 We	5 Martins		14.9 nm	PG2	SD	0 11001717	Martins	14.5	nm PG2		SD 110017	717	2.11.16	5 We	FL2 Operation	14.9 nm -	44.7 nm				FL2 Operation	1	4.9 nm -	44.7 nm		
3.11.16 Th	Martins		14.9 nm	PG2	SD	0 11001717	Martins	14.5	nm PG2		SD 110017	17	3.11.16	5 Th	FL2 Operation	14.9 nm -	44.7 nm				FL2 Operation	1-	4.9 nm -	44.7 nm		
4.11.16 Fr	4 von Korff Sc	hmising	20.8 nm	BL2		11001719	von Korff Schmi	ising 20.1	8 nm BL2		110017	719	4.11.16	5 Fr 6	Moshammer/Schnorr	51.8 nm	FL26		11000976		Moshammer/Schnorr		51.8 nm	FL26	11000976	
5.11.16 Sa	von Korff Sc	hmising	20.8 nm	BL2		11001719	von Korff Schmi	ising 20.	3 nm BL2		110017	719	5.11.16	5 Sa	Moshammer/Schnorr	51.8 nm	FL26		11000976		Moshammer/Schnorr		51.8 nm	FL26	11000976	
6.11.16 Su	5 Ulrich		16.0 nm	PG1		11001736b	Ulrich	16.	) nm PG1		110017	736b	6.11.16	5 Su	FL2 Operation	16 nm -	48 nm				FL2 Operation	1	16 nm -	48 nm		
7.11.16 Mo	4 von Korff Sc	hmising	20.8 nm	BL2		11001719	von Korff Schmi	ising 20.	8 nm BL2		110017	719	7.11.16	5 Mo	FL2 Operation	20.8 nm -	62.4 nm				FL2 Operation	2	0.8 nm -	62.4 nm		
8.11.16 Tu	von Korff Sc	hmising	20.8 nm	BL2	L.	11001719	von Korff Schmi	ising 20.	8 nm BL2	L	110017	719	8.11.16	5 Tu	FL2 Operation	20.8 nm -	62.4 nm				FL2 Operation	2	0.8 nm -	62.4 nm		
9.11.16 We	5 Ulrich		16.0 nm	PG1		11001736b	Ulrich	8.1	nm PG1		110017	736a	9.11.16	5 We	FL2 Operation	16 nm -	48 nm				FL2 Operation	1	16 nm -	48 nm		
10.11.16 Th	Maintenand	e					Setup (Reference	ce files)					10.11.16	5 Th	Maintenance						Setup (Reference files)					
11.11.16 Fr	4 von Korff Sc	hmising	20.8 nm	BL2		11001719	von Korff Schmi	ising 20.	8 nm BL2		110017	719	11.11.16	5 Fr 6	Moshammer/Schnorr	20.7 nm	FL26		11002462a		Moshammer/Schnorr		20.7 nm	FL26	11002462a	
12.11.16 Sa	von Korff So	hmising	20.8 nm	BL2	L L	11001719	von Korff Schmi	ising 20.	8 nm BL2	L L	110017	719	12.11.16	5 Sa	Moshammer/Schnorr	20.7 nm	FL26		11002462a		Moshammer/Schnorr		20.7 nm	FL26	11002462a	
13.11.16 Su	5 Ulrich		16.0 nm	PG1		11001736b	Ulrich	16.	) nm 👘 PG1		110017	736b	13.11.16	5 Su	FL2 Operation	16 nm -	48 nm				FL2 Operation	1	16 nm -	48 nm		
14.11.16 Mo	5 Ulrich		8.1 nm	PG1		11001736a	Ulrich	8.1	nm PG1		110017	736a	14.11.16	6 Mo 6	Moshammer/Schnorr	20.7 nm	FL26		11002462a		Moshammer/Schnorr	1	20.7 nm	FL26	11002462a	
15.11.16 Tu	Ulrich		8.1 nm	PG1		<b>11001736</b> a	Ulrich	8.1	nm PG1		110017	736a	15.11.16	5 Tu	Moshammer/Schnorr	20.7 nm	FL26		11002462a		Moshammer/Schnorr	2	20.7 nm	FL26	11002462a	
16.11.16 We	5 Boll		6.2 nm	BL1	L	11001729c	Boll	6.2	nm BL1	L	110017	729c	16.11.16	5 We	FL2 Operation	6.2 nm -	18.6 nm				FL2 Operation	6	5.2 nm -	18.6 nm		
17.11.16 Th	Boli		6.2 nm	BL1	L	11001729c	Boll	6.2	nm BL1	L	110017	729c	17.11.16	5 Th	FL2 Operation	6.2 nm -	18.6 nm				FL2 Operation	6	5.2 nm -	18.6 nm	-	
18.11.16 Fr	5 Ulrich		8.1 nm	PG1		11001736a	Ulrich	8.1	nm PG1		110017	736a	18.11.16	5 Fr	FL2 Operation	8.1 nm -	24.3 nm				FL2 Operation	8	3.1 nm -	24.3 nm		
19.11.16 Sa	5 Boll		6.2 nm	BL1	L	11001729c	Boll	6.2	nm BL1	L	110017	729c	19.11.16	5 Sa	FL2 Operation	6.2 nm -	18.6 nm				FL2 Operation	6	5.2 nm -	18.6 nm		
20.11.16 Su	Boll		6.2 nm	BL1	t	11001729c	Boll	6.2	nm BL1	l	110017	/29c	20.11.16	SSu 5	Moshammer/Schnorr	13.8 nm	FL26		11002462b		Moshammer/Schnorr		13.8 nm	FL26	11002462b	
21.11.16 Mo	Boll	during of the l	6.2 nm	BL1	L L	11001729c	Boll	6.2	nm BL1	L	110017	7290	21.11.16	5 Mo	Moshammer/Schnorr	13.8 nm	FL26		11002462b		Moshammer/Schnorr		13.8 nm	FL26	11002462b	
22.11.16 Tu	Contingence	(user@FL2)		014		44004707	Contingency (us	ser @ FL2)				100	22.11.16	5 Tu	Moshammer/Schnorr	13.8 nm	FL26		11002462b		Moshammer/Schnorr		13.8 nm	FL26	11002462b	
23.11.16 We	4 Boll		6.2 nm	BL1	1	11001729c	Boll	6.2	nm BL1		110017	290	23.11.16	5 We	Shutdown						Shutdown					
24.11.16 Th	2 BOIL		4.2 nm	BEI	L.	11001729b	ROIL	4.2	nm BL1	- L	110017	290	24.11.16	5 Th	Shutdown						Shutdown					
User		wave	ength	# bunch	es ren rate	nulse dur.	nulse energy	Beamline fo	cus? Laser	/THz Solit	+ delay applic	ation #														
Schnell		30.3 nm +/	- 1.00 nm	1	es reprinc	< 50 fs	50 µ	BL1	L	,	11001	711		U	ser	wave	length	#bunches	rep rate	pulse dur.	pulse energy	Beamline fo	ocus? Las	ser/THz Split	+ delay application #	
Martins		14.9 nm +/	- 0.10 nm	80	200kHz	< 50 fs	max. μ	PG2			SD 11001	717		N	loshammer/Schnorr	51.8 nm +/	- 1 nm	80	200kHz	50 fs	10 µJ	FL26			11000976	
von Korff Schmi	ising	20.8 nm +/	- 0.10 nm	1		< 50 fs	50 µJ	BL2	L. L.		11001	719		N	loshammer/Schnorr	20.7 nm		40	100kHz	50-100 fs	50 µJ	FL26			11002462a	
Boll		16.5 nm +/	- 0.10 nm	1		< 50 fs	max. μ	BL1	L. L		11001	729a		N	loshammer/Schnorr	13.8 nm		40	100kHz	50-100 fs	50 µJ	FL26			11002462b	

11001736a

## **FLASH** multiple beamlines



#### New FLASH 2 publication:

B Faatz, E Plönjes, et al : Simultaneous operation of two soft x-ray freeelectron lasers driven by one linear accelerator New J. Phys. 18 062002 (2016)



#### 3 FELs in parallel:

T Plath et al **Free-electron laser multiplex driven by a superconducting linear accelerator.** J Synchrotron Radiat. **23** 1070 (2016)

## Online diagnostic tools .



The *Atomic Photoionization Process* is a perfect candidate for non-destructive, pulse-resolved photon metrology tools.

- ➢ intensity
- beam position
- > spectral distribution
- ➢ polarisation
- > XUV pulse duration
- ➤ coherence
- ➢ focus size

Gas-Monitor Detectors (GMD)

**GMD Split Electrodes** 

Photoionization spectra / VLS grating

Photoemission distribution

THz streaking

split & delay lines, diffraction

wave-front sensor

The effort for developing such detector systems is extremely high, in particular due to the tight requirements on robustness and reliability.

#### Online intensity and beam position monitoring.







Pulse resolved energy and beam position (FLASH2)



- > Online quality checks
  - traffic light indicators
  - resolution checks for measured parameters



## Online measuring wavelength using photoionization.





#### Gas based detectors – Polarization measurement.





Polarisation: Measurement of angular distribution of the emitted photoelectrons by 16 TOFs.

Not yet integrated in the Beamlines Collaboration with J. Viefhaus (PETRA III) Allaria E et al Phys. Rev. X **4** 041040 (2014) Düsterer etJ. Phys. B: At. Mol. Opt. Phys. **49** 165003 (2016)

basic geometry



- photon energies between 30 eV and 70 eV (3d metal M edges)
- Available for BL1, 2 and 3
- ~ 10% transmission
- maximal degree of circular polarization around 80%



## The most difficult one - pulse duration



Extensive study on different techniques: Düsterer et al, PRSTAB 17, 120702 (2014)

- non-invasive
- online monitoring
- single bunch resolved measurement

#### **THz Streaking**

(permanent installation at FLASHII planned for 2017/8)

Measuring the pulse duration and arrival time by means of a single cycle THz streaking field.

Nat. Photonics **3**, 523 (2009), Nat. Photonics **6**, 852 (2012)



#### **Pulse duration for different FEL settings**



7 nm, 15 µJ, 0.20 nC -> ~30 fs FWHM

7 nm, 50 µJ, 0.35 nC -> ~ 120 fs FWHM



#### Arrival time measurements -> precission for pump-probe





- Measuring electron bunch arrival time 200 m away from the experiment
- Comparing to Pump-probe laser vs XUV pulse





FLASH facility present and future

## Science@FLASH





~80 % time-resolved (pump-probe) experiments

- ~ 50% Optical/XUV
- XUV/XUV
- THz/XUV

### FLASH1 User Period 7 (January – June 2016)





#### **FLASH – plans for 2017 to 2020**





#### Variable gap undulators for FLASH1

#### > external seeding FLASH2



#### HGHG @ SFLASH

#### Variable polarization (Delta undulator)



## FLASH2020 – A High-Repetition Rate Soft X-Ray Camera



#### FLASH2020

- cw operation up to 1MHz
- fundamental 30-550eV
- multiple FEL lines with up to 100kHz
- external seeding up to 100kHz
- complementary to XFEL/LCLS-II

#### **SCIENCE**

- Time-resolved coincidences
- Electronic structure movies
- Single-shot nanoscale imaging
- Light-induced dynamics and control
- Nonlinear spectroscopy







FLASH facility present and future



### FLASH1 User Period 7 (January – June 2016)





## Science@FLASH





~80 % time-resolved (pump-probe) experiments

- ~ 50% Optical/XUV
- XUV/XUV
- THz/XUV

#### First users at FLASH2 – April 2016







#### THz Streaking at FLASH 2



So far "commissioning" beamtimes (at FLASH1)



## THz streaking setup





### **Online VLS grating spectrometer**

> Higher resolving power as OPIS



Brenner, C. et al.. NIM A, 635 (2011) S99-S103

## **Online VLS spectrometer with fast 1D detector**



#### https://www.psi.ch/detectors/gotthard





## **Online Wavelength Spectrometer OPIS @ FLASH2.**



